Translation





PCT

INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY (Chapter II of the Patent Cooperation Treaty)

(PCT Article 36 and Rule 70)

Applicant's or agent's file reference PC-9015	FOR FURTHER ACT	FION	See Form PCT/IPEA/416
International application No. PCT/JP2003/015427	International filing date		Priority date (day/month/year)
	02 December 2003		02 December 2002 (02.12.2002)
International Patent Classification (IPC) or n G03F 7/40, H01L 21/027	national classification and	IPC	
Applicant	ТОКУО ОНКА КО	GYO CO., LTD	
This report is the international preling Authority under Article 35 and trans	minary examination report smitted to the applicant ac	t, established by this cording to Article 3	S International Preliminary Examining 6.
2. This REPORT consists of a total of		ncluding this cover s	sheet.
3. This report is also accompanied by			
a. (sent to the applicant and	l to the International Bure	au) a total of	sheets, as follows:
sheets of the desc and/or sheets con Administrative In	taining rectifications author	wings which have b orized by this Autho	een amended and are the basis of this report ority (see Rule 70.16 and Section 607 of the
sheets which super beyond the disclosure Supplemental Box	sure in the international a	which this Authority application as filed,	y considers contain an amendment that goes as indicated in item 4 of Box No. I and the
	, containing dicated in the Supplement	ng a sequence listin	pe and number of electronic carrier(s)) g and/or tables related thereto, in computer o Sequence Listing (see Section 802 of the
4. This report contains indications rela	ting to the following items	s:	
Box No. I Basis of the re	eport		
Box No. II Priority			
Box No. III Non-establish	ment of opinion with rega	rd to novelty, invent	tive step and industrial applicability
Box No. IV Lack of unity	of invention		
Box No. V Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement			
Box No. VI Certain documents cited			
Box No. VII Certain defects in the international application			
Box No. VIII Certain observ	vations on the internationa	l application	
Date of submission of the demand	ı	Date of completion o	of this report
27 May 2004 (27.05.2	2004)	06 October 2004 (06.10.2004)	
Name and mailing address of the IPEA/JP	A	Authorized officer	
Facsimile No.	1	Celenhone No.	



INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

International application No. PCT/JP2003/015427

Box No.	I Basis of the report	
	regard to the language, this report is based on the international application in the language wise indicated under this item.	ge in which it was filed, unless
	This report is based on translations from the original language into the following lar which is language of a translation furnished for the purpose of:	nguage,
	international search (under Rules 12.3 and 23.1(b))	
	publication of the international application (under Rule 12.4)	
	international preliminary examination (under Rules 55.2 and/or 55.3)	
furnis	regard to the elements of the international application, this report is based on (repshed to the receiving Office in response to an invitation under Article 14 are referred to the report): The international application as originally filed/furnished	placement sheets which have been to in this report as "originally filed"
	the description:	
🖳	pages	, as originally filed/furnished
	pages* received by this Authority on	, as originary measurationed
	pages* received by this Authority on	
	the claims:	
	pages	, as originally filed/furnished
		er with any statement) under Article 19
}	pages* received by this Authority on	,
	pages* received by this Authority on	
	the drawings:	
	pages	, as originally filed/furnished
	pages* received by this Authority on	, as originarly invariant
	pages* received by this Authority on	
	a sequence listing and/or any related table(s) – see Supplemental Box Relating to Seque	nce I isting
	a sequence name and or any related table(s) see Supplemental Dev Relating to seque.	nee bisting.
3.	The amendments have resulted in the cancellation of:	
	the description, pages	
	the claims. Nos.	
ļ		
	the drawings, sheets/figs	
	the sequence listing (specify):	
	any table(s) related to sequence listing (specify):	
4.	This report has been established as if (some of) the amendments annexed to this report made, since they have been considered to go beyond the disclosure as filed, as ind (Rule 70.2(c)). the description, pages the claims, Nos.	
Į.	the drawings, sheets/figs	
	the sequence listing (specify):	•
	any table(s) related to sequence listing (specify):	
1		
* If iten	m 4 applies, some or all of those sheets may be marked "superseded."	



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. Statement			
Novelty (N)	Claims	1-8	YES
	Claims	9, 10	NO
Inventive step (IS)	Claims		YES
	Claims	1-10	NO
Industrial applicability (IA)	Claims	1-10	YES
	Claims		NO

2. Citations and explanations (Rule 70.7)

Document 1: JP, 5-315241, A (K.K. Sorutekku), 26 November, 1993 (26.11.93), claim 1, paragraphs [0022]-[0028]

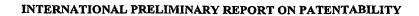
Document 2: JP, 2002-299223, A (Matsushita Electric Industrial Co., Ltd.), 11 October, 2002 (11.10.02), paragraphs [0014] and [0028]-[0044]

Document 3: JP, 2000-338674, A (Fuji Photo Film Co., Ltd.), 8 December, 2000 (08.12.00), claim 1, paragraphs [0131]-[0134]

Document 4: JP, 9-82629, A (K.K. Sorutekku), 28 March, 1997 (28.03.97), claim 1, paragraph [0019] Document 5: JP, 7-226358, A (Hitachi, Ltd.), 22 August, 1995 (22.08.95), the claims

The subject matters of claims 1 and 6-8 do not appear to involve an inventive step in view of documents 1-3. Document 1 describes a resist pattern forming method wherein, in a rinsing process in the development of a resist pattern, a substituent liquid for a rinsing liquid is made into a critical state in the drying. Documents 2 and 3 describe a positive resist composition having a less than 20 mol% content of alkali soluble units and an acid-dissociation solution suppressing group, and containing a resin component (A) whose alkali solubility increases due to the effect of an acid, an acid producer component (B) to produce an acid by exposure to light, and an organic solvent (C) to dissolve the components (A) and (B). A person skilled in the art could have easily used the positive resist composition taught in documents 2 and 3 in the resist pattern forming method described in document 1.

The subject matters of claims 2, 4 and 5 do not appear to involve an inventive step in view of documents 1-5. Documents 4 and 5 describe an invention wherein water rinsing is performed after the alkali development and then the substitution by a fluorine-inactive liquid is performed. A person skilled in the art could have easily adopted the inventions taught in documents 4 and 5 for the resist pattern forming method described in document 1.



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Box No. VI Certain documents cited

Application No. Patent No.	Publication date (day/month/year)	Filing date (day/month/year)	Priority date (valid claim) (day/month/year)
JP 2003-243352 A	29.08.2003	23.04.2002	10.12.2001
[E, X]			
JP 2003-142368 A	16.05.2003	31.10.2001	
[E, X]			
JP 2003-337406 A	28.11.2003	22.05.2002	
[E, X]			
JP 2003-92240 A	28.03.2003	18.09.2001	
[E, X]			

2. Non-written disclosures (Rule 70.9)	2.	Non-written	disclosures ((Rule 70.9)	ì
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Kind of non-written disclosure

Date of non-written disclosure (day/month/year)

Date of written disclosure referring to non-written disclosure (day/month/year)



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Box No. VIII Certain observations on the international application

The following observations on the clarity of the claims, description, and drawings or on the question whether the claims are fully supported by the description, are made:

The disclosure of the specification in the sense of PCT Article 5 is only a resist pattern forming method wherein (1) water rinsing is performed after the alkali development, (2) then the liquid present on the board is replaced with a first fluorine inactive liquid, (3) then the said liquid present on the board is replaced with a second fluorine-inactive liquid containing a surfactant, (4) then the replacing liquid is replaced with a critical drying liquid, and (5) a drying process wherein the said critical drying liquid is dried through a critical state is performed.

Accordingly, the subject matters of claims 1-10 are not supported by the disclosure of the specification in the sense of PCT Article 6.



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Supplemental Box

In case the space in any of the preceding boxes is not sufficient. Continuation of: V

The subject matter of claim 3 does not appear to involve an inventive step in view of documents 1-4. Document 4 describes that a rinsing liquid added with a surfactant is used. A person skilled in the art could have easily adopted the invention taught in document 4 in the invention described in document 1.

The subject matters of claims 9 and 10 do not appear to be novel in view of document 2. Document 2 describes a resist pattern having a high aspect ratio with a thickness of 0.4 μ m, and a line width of 0.11 μ m or 0.10 μ m. The subject matters of claims 9 and 10 as a resist pattern are the same as the invention described in document 2.